

FIGURE 1

**Arsenic Residues in Resist:
Trench Array Sample,
Arsenic Glass Process
w/Drive-In,
Photoresist Fill**

File:

CP1520-A-010049A-Resist-AsResidues

14.5KeV Cs

C.C.Parks B. Conlin, 4f 10/00

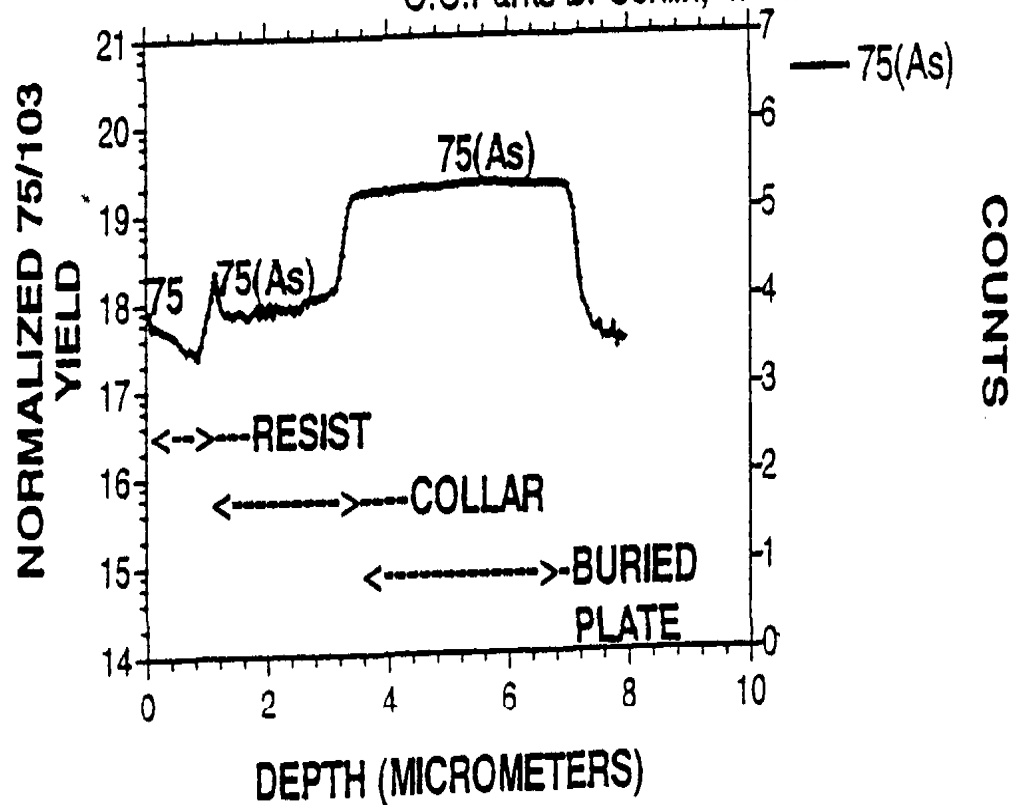


FIGURE 2

ASG, DRIVE In,
Node Deposition
prior to resist fill

File: CP1520-M-010059-Resist-NodePrior

14.5KeV Cs

C.C.Parks B. Conlin, 4f 10/00

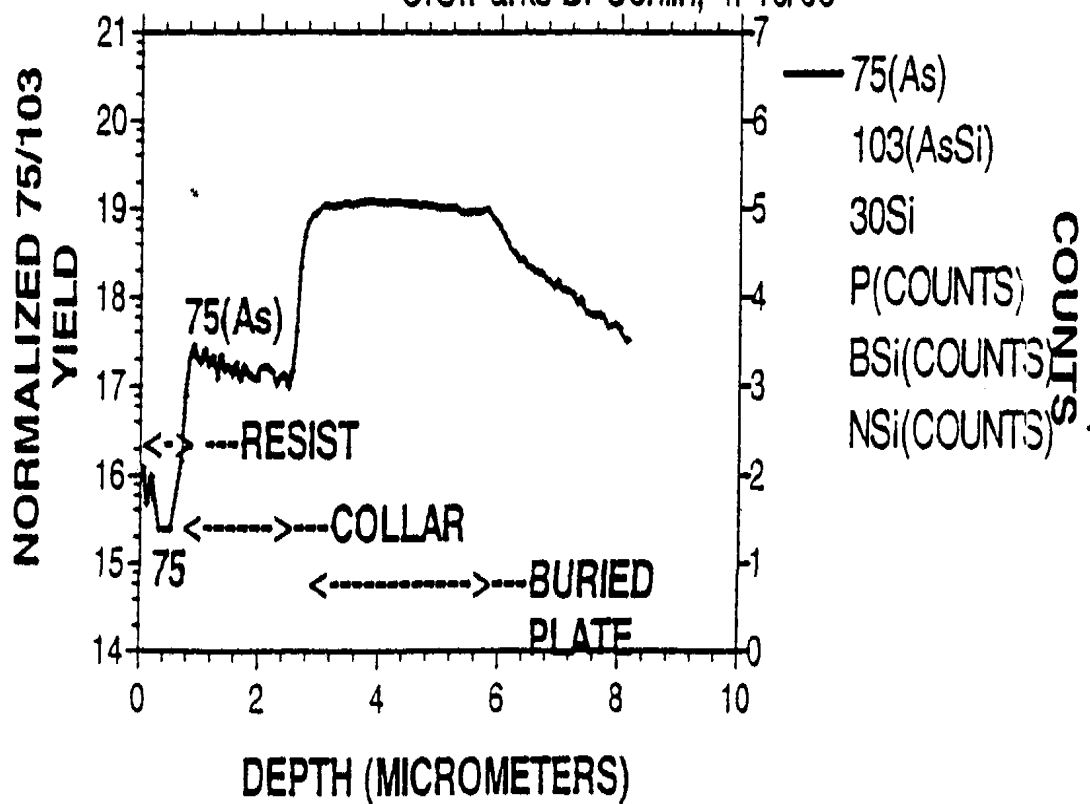


FIGURE 3

